



## Nanocrystalline Silicon Oxide in Silicon Heterojunction Solar Cells

Alexei Richter

Energie & Umwelt / Energy & Environment

Band / Volume 416

ISBN 978-3-95806-310-5

Forschungszentrum Jülich GmbH  
Institut für Energie- und Klimaforschung  
IEK-5 Photovoltaik

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Schriften des Forschungszentrums Jülich  
Reihe Energie & Umwelt / Energy & Environment

Band / Volume 416

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ISSN 1866-1793

ISBN 978-3-95806-310-5

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